

Flue Gas Analyzer EM-5

Environment Online Monitoring/Industrial Process Control/Safety Monitoring







Focusing on

Environmental & Industrial Analysis

Company Profile

Hangzhou Zetian technology Co., Ltd., located in Binjiang, Hangzhou, Zhejiang Province, China, is a high-tech enterprise, which integrates R&D, production and sales of online monitoring instrument in environmental monitoring field, industrial monitoring field and industrial safety field. Our company covers an area of over 20,000 square meters, including office and production district.

Our company manufactures in strict accordance with ISO9001/14001 quality assurance system. Introduced advanced ERP and TOC management system to guarantee our product and service superior and reliable, our company make great progress through joint effort of the whole employees. Up to this day, our product integrates technologies of multiple fields, including optics, micro-electronics, software, communication, mechanical and electrical engineering, analytical chemistry and etc. We are an innovative enterprise with multifarious detection technology of independent property in analysis and detection of gas, water quality and dust field.

We owns powerful R&D strength with wide product application fields: online monitoring field of gas pollution source, water pollution source and water environment, atmospheric environment monitoring field, process analysis and process safety field, etc.

We trade with many corporate customers, including environmental protection department, domestic and foreign on-line gas/water pollution source monitoring, gas/water environment online monitoring and process analysis system integrators, agents, operation and maintenance providers; equipment manufacturers, thermal power plants, sewage treatment plants, steelworks, metallurgy industry, chemical plants and the like. We provide our clients with highly cost-effective analysis equipment, analysis module/component, CEMS program, water quality analysis program, process analysis program and other similar products. We accept OEM and also provide service of ODM, operation and maintenance and etc.

As a high-tech instrument manufacturer, we pay high attention to R&D talent team establishment. With rich experience in the industry, our core team took part in national major scientific projects got awards. In addition, our company owns more than 100 national patents and software copyrights.













Overview

EM-5 series flue gas analyzer is a series of self-developed gas analysis products for online gas analysis of domestic as well foreign environmental protection and industrial control. Based on UV Differential Optical Absorption Spectroscopy (DOAS) technology and chemometrics algorithm (PLS), it is able to measure gas concentration of SO₂, NO, NO₂, O₂, NH₃, Cl₂, O₃, H₂S, Ch₃ and etc. With features of high measurement accuracy, high reliability, fast response time, wide application scope, it can be widely applied in occasions of environment online monitoring, industrial process control, safety monitoring and etc.

Depended on years of flue gas analyzer research experience and combined with practical experience of thousands of successful application cases, the analyzer has derived multiple types (standard type, low emission type, ultra-low emission type, and customized type) to meet different index requirements in different working condition.

Technical Principle

EM-5 flue gas analyzer adopts UV DOAS technology. The optical technology platform consists of light source, gas chamber, optical fiber and spectrograph (including diaphragm, holographic grating, linear array detector) and other optical components. Please refer to figure 1, figure 2, and figure 3.

Ultraviolet light emitted by light source enters gas chamber by optical window and absorbed by measured sample gas flowed through gas chamber. The light carrying sample absorption information will be gathered by lens and coupled into optical fiber and then transmits into spectrometer through fiber. After light splitting and photo-voltaic conversion, gas absorption spectrum is obtained.

The corresponding component concentration in gas can be calculated by analyzing spectrum.

Note: the difference among standard analyzer, low emission analyzer and ultra-low analyzer is the different optical path length of gas chamber: for standard analyzer, it adopts dual lens collimation system with 0.25m optical path; for low emission analyzer, it adopts multiple return structure with 1m optical path; for ultra-low emission analyzer, it uses white cell structure with adjustable optical path of 5-15m.

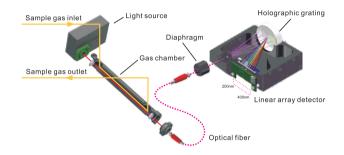


Fig.1 Standard (0.25m optical path)

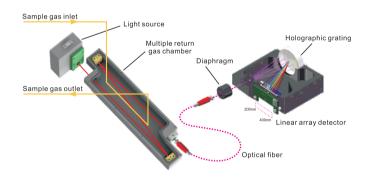


Fig.2 Low emission (1m optical path)

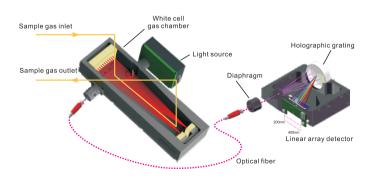


Fig.3 Ultra-low emission (5-15m optical path, adjustable)

■ Technical Feature

High measurement accuracy

- Minimum detection limit of SO₂, NO, NO₂ can reach 1mg/m³ (15m optical path)
- Ultraviolet has no moisture absorption, undisturbed by moisture and dust
- No cross interference between measured gases (refer to table 1)
- Measure NO and NO2 simultaneously without converter
- · Low detection limit

High reliability

- · Small zero drift and span drift
- · Modular design
- No optical moving parts, without vibration influence
- · Strong gas chamber, low cost
- Automatic adjustment spectrum technology, long maintenance-free period
- Adopt pulse light source with 10-year service life

Table1: Cross Interference between Gases Table

Measuring gas Interfering gas	SO ₂	NO	NO ₂	O ₂
SO ₂ (500ppm)	/	< 1ppm	no	no
NO (500ppm)	no	/	no	no
NO ₂ (500ppm)	no	< 1ppm	/	no
H ₂ O (No dew)	no	no	no	no
CO (1000ppm)	no	no	no	no
CO ₂ (20%)	no	no	no	no
O ₂ (21%)	no	no	no	/

Wide application scope

- · Coal-fired power plant
- · Cement plant
- Industrial furnace
- $DeSO_x$ process monitoring
- DeNO_x process monitoring
- Waste incineration plant
- PVC process in chlor-alkali plant
- Titanium dioxide production process
- Sulfur recovery process
- Natural gas purification process
- Methyl iodide analysis for the coal chemical industry
- On-line air monitoring

■ Technology Comparison

NDIR Technology	FTIR Technology	UVF + Chemiluminescence Technology	UV DOAS	
Low cost	High cost	High cost	Low cost	
Measure fewer components, generally, single gas chamber can only measure one kind	The largest advantage is able to measure over 10 components	Measure fewer components, different component adopt different measuring principle	The single gas chamber can measure 3-5 components	
With optical moving parts, poor reliability	The interferometer is optical moving part	No optical moving parts	Adopt full spectrum electronic scanning, without optical moving parts	
Single or dual wavelength	Full infrared spectrum measurement	Sensitive to some interferences, such as background fluorescence, quenching effect, and etc.	Full UV spectrum measurement technology, not affected by cross interference	
Fast response, long preheating time	Restricted by scanning time, slow response, need preheating	Fast response, poor stability and reproducibility caused by high light background	Fast response, no preheating	
Low measurement accuracy, large drift	High measurement accuracy and small drift	High measurement accuracy and large drift	High measurement accuracy, small drift	
High requirements for measured gas, no dust and low dew point	High requirements for measured gas, no dust and low dew point	High requirements for measured gas, no dust and low dew point	Water and a small amount of dust will not affect measurement	
Adopt continuous light source, service life is only thousands of hours	Adopt continuous light source, service life is only thousands of hours	Adopt continuous light source, service life is only thousands of hours	Adopt pulse light source, with service life of ten years	
High detection limit	Low detection limit	Low detection limit	Low detection limit, the minimum can reach 1 mg/m ³	

■ Technical Specification

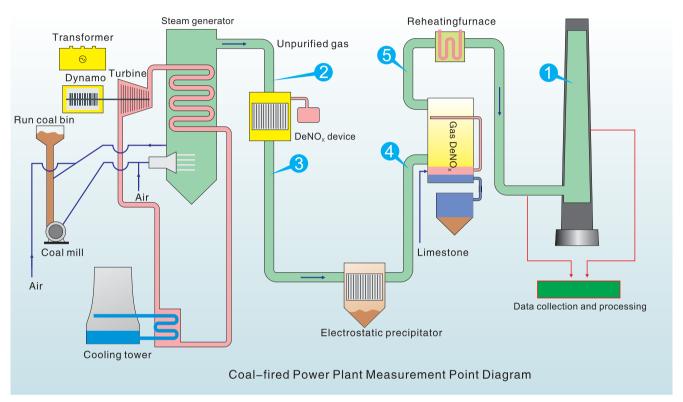
		Standard		Low Emission		Ultra-low Emission	
Appearance							
Measurement Principle		UV-DOAS+PLS					
Typical measurement		Min range	Max range	Min range	Max range	Min range	Max range
	SO ₂	0 ~ 300ppm	0 ~ 3000ppm	0 ~ 100ppm	0 ~ 300ppm	0 ~ 50ppm	0 ~ 100ppm
0	NO	0 ~ 300ppm	0 ~ 3000ppm	0 ~ 100ppm	0 ~ 300ppm	0 ~ 50ppm	0 ~ 100ppm
Component	NO ₂	0 ~ 500ppm	0~4000ppm	0 ~ 300ppm	0 ~ 1000ppm	0 ~ 100ppm	0 ~ 200ppm
	O ₂	0 ~ 5%	0~25%	0 ~ 5%	0~25%	0~5%	0~25%
Linearity				≤ ± 3	3%F.S.		
Repeatability	Repeatability ≤2%						
Zero Drift				≤ ± 2%	%F.S./7d		
Span Drift		≤ ± 2%F.S./7d					
Response Ti	sponse Time(T90) ≤50s						
Working Tem	perature			-20℃	~ +50°C		
Preheating Time		No pre	heating	20min 40min)min
Sample Gas	Interface	Φ6 Bi-Lok					
Sample Gas	Flow		Ra	ınge: (0.5 ~ 2)L/m	nin, fluctuation < 2	25%	
Sample Gas	Pressure			Current ambient	pressure ±0.1Ba	ar	
Sample Gas	Temperature			0℃~	+ 50°C		
Sample Gas	Humidity		No cond	ensation (under	sample gas tem	perature)	
4–20mA Inpu	ut Interface			3 , configurat	ole, 100Ω load		
4–20mA Out	put Interface	5, output content can be configured, maximum load capacity ≤800 Ω					
Switch Input	Interface	6 , configurable					
Relay Outpu	t Interface	e 14, output content can be configured. DC30V2A					
Communicat	Communication Interface 1×RS232, 1×RS485 (Support Modbus protocol)						
Installation N	allation Method Installed in 19 inch cabinet						
Supply Volta	pply Voltage 220VAC ± 10%						
Rated Power A		Abou	t 100W	About 120W			
Dimension 13		132(H)x483(W)x375(D)mm	177(H)x483(W)x412(D)mm 177(H)x483(W)x49		W)x492(D)mm	
Weight About 10kg About 15kg							

■ External Dimension

	Standard	Low Emission	Ultra-low Emission	
Front view	8.8 380 465 482.6	8.8 380 465 462.6	8.8 380 465 482.6	
Rearview	\$\frac{52}{25}\$ \$\frac{52}{25}\$ \$\frac{52}{25}\$ \$\frac{52}{25}\$ \$\frac{52}{25}\$ \$\frac{52}{25}\$ \$\frac{7}{47}\$ \$\frac{7}{47}\$ \$\frac{7}{45}\$	52 52 52 52 52 52 52 52 52 52	21.7 35, 35	
Top view	440	440 90 PB	H U H	
Side view	349.4 332.4 322.4 3 8 8 8 14 25	384 367 360 380 380 380 380 380 380 380 38	7 448 440 440 7 441 7 440 7 4 7 441 7 440 7 440	
Perspective View				

■ Typical Application

Coal-fired power plant is the major emission source of atmospheric pollution, including particulate matter, SO_2 , NO_x and etc. It affects economic development and damages both living as well as ecological environment. The main method for controlling process and exhaust emission to reach ultra-low discharge standard and optimize process is through gas component monitoring.



Measurement Point No.	Detection Point	Temp	Pressure	Measuring component	Monitoring Purpose	Recommended product
Point 1	Main emission stack	Normal	Micro-positive pressure	CEMS (five-parameter)	Online monitor emission of each component in exhaust gas	EM-5
Point 2	Before DeNO _x	Normal	Micro-positive pressure	NO _x , O ₂	Monitor efficiency of DeNO _x device in real time	EM-5
Point 3	After DeNO _x	Normal	Micro-positive pressure	NO _x , O ₂ , NH ₃	Monitor efficiency of DeNO _x device in real time	EM-5, LGT-100 or GA-5000
Point 4	Before DeNO _x	Normal	Micro-positive pressure	So ₂ , O ₂	Monitor efficiency of DeNO _x device in real time	EM-5
Point 5	After DeNO _x	Normal	Micro-positive pressure	So ₂ , O ₂	Monitor efficiency of DeNO _x device in real time	EM-5

*For detail, please refer to selection our manual and product sample

Look forward to working with you

Focusing on Environmental & Industrial Analysis

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